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Supporting Information

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A Layer-by-Layer Assembly Route to Electroplated Fibril-Based 3D Porous Current Collectors for Energy Storage Devices

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Detailed Experimental Sections

Characterization

FT-IR spectra of the multilayers were obtained using a CARY 600 spectrometer (Agilent Technology) in specular mode with a resolution of 4 cm^{-1}, and the collected data were plotted with spectrum analysis software (OMNIC, Nicolet). FE-SEM and EDS data were obtained using an S-4800 instrument (Hitachi). Transmission electron microscopy (TEM) data of synthesized NPs were obtained using a Tecnai 20 instrument (FEI). UV-vis spectra of the LbL-assembled multilayer on quartz glass slides were analyzed using a Lambda 35 instrument (Perkin Elmer) within a scan range of 200 – 800 nm. The quantitative deposition of multilayers was monitored through a quartz crystal microbalance QCM (QCM 200, SRS). The mass loading of each layer was converted from the QCM frequency change using the Sauerbrey equation.[S1] The electrical conductivity of the

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electrode was monitored by four-probe measurement. The temperature dependence of the electrical conductivity of LbL-assembled Au NP-coated paper and Ni-EPs was measured using a physical property measurement system (PPMS-9, Quantum Design) over a temperature range from 2 to 300 K.

Electrochemical Measurements

The electrochemical investigation for all electrodes was conducted in a three-electrode configuration through an Ivium-n-stat (Ivium Technologies). The Ag/AgCl (3 M NaCl) electrode, Pt coil electrode, and pseudocapacitive NP/Ni-EP (active area of 1 cm^2) were used as the reference, counter, and working electrodes, respectively in 0.5 M Na_2SO_4 electrolyte. CV and GCD measurements were all investigated in the potential range of 0 V to 1 V. EIS measurements were performed in the frequency range of 100 kHz to 0.1 Hz with a perturbation amplitude of 0.01 V.

The electrochemical capacitance of the MnO/Ni-EP electrode was calculated with the following equations.[S2]

$$\text{Specific capacitance (C)} = \frac{\int i(V)dV}{2v\Delta VS} \quad \text{(for CV)} \tag{1}$$

$$\text{Specific capacitance (C)} = \frac{I\Delta t}{\Delta V} \quad \text{(for galvanostatic charge/discharge measurements)} \tag{2}$$

where i, v, ΔV, I, and Δt represent the current, scan rate (mV s^{-1}), operating voltage window (potential range), applied current density, and discharge time, respectively. The variable S in Eq. (1) indicates the active area of the electrode or mass of the active material.
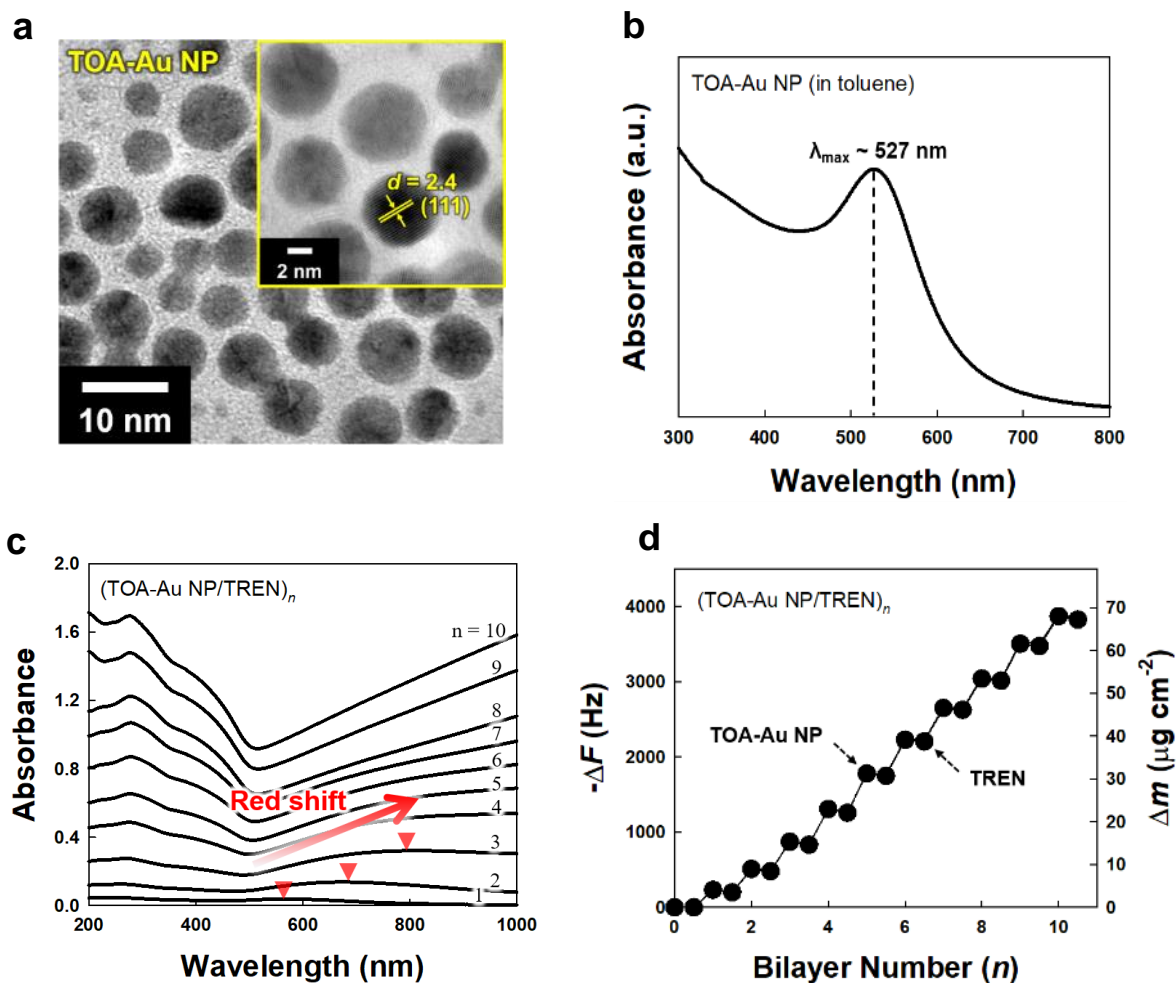
Figure S1. a) HR-TEM images of TOA-Au NP with a diameter of approximately 8 nm. b) UV-Vis spectra of TOA-Au NP in toluene. The TOA-Au NP in toluene exhibits the Surface resonance absorption peak at 527 nm. c) UV-Vis spectra of (TOA-Au NP/TREN)$_n$ multilayers as a function of the bilayer number (n). In this case, the absorption peaks of surface plasmon resonance spectra were strongly red-shifted with increasing the bilayer number (n) of (TOA-Au NP/TREN)$_n$ multilayers. d) QCM data for the (TOA-Au NP/TREN)$_n$ multilayer films as a function of the bilayer number (n).
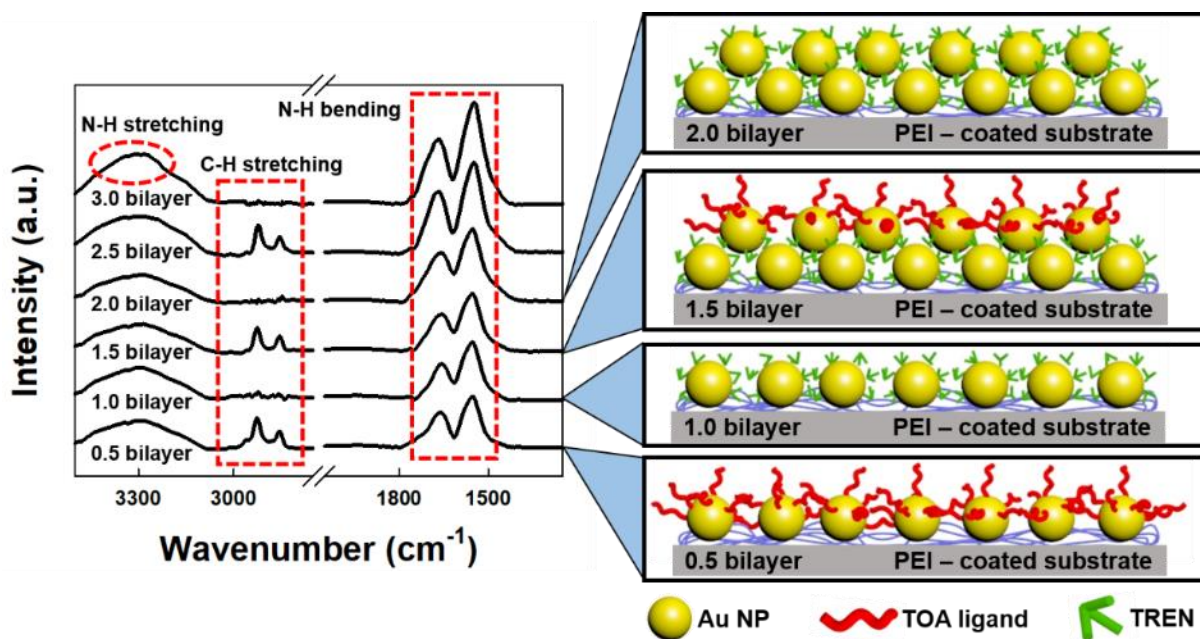
Figure S2. Fourier transform infrared (FT-IR) spectra and schematic illustration of the (TOA-Au NP/TREN)$_n$ multilayer films as a function of the bilayer number (*n*). As shown in the FT-IR spectra, the deposition of TOA-Au NP onto the poly(ethylene imine) (PEI)–coated Si substrate generated C-H stretching peaks from the long alkyl chains of TOA ligands at 2850 ~ 2950 cm^{-1} (herein, PEI containing large amounts of amine groups have a high affinity to the bare surface of Au NPs). When TREN was further deposited onto the outermost TOA-Au NP layer, the C-H stretching peaks disappeared, while the N-H bending peaks at 1550 ~ 1650 cm^{-1} and N-H stretching peaks at 3300 – 3500 cm^{-1} gradually increased. Therefore, the alternating deposition of TOA-Au NP and TREN repeated the generation and disappearance of the C-H stretching peaks originating from the TOA ligands when the outermost layer was changed from TOA-Au NP to TREN and vice versa.
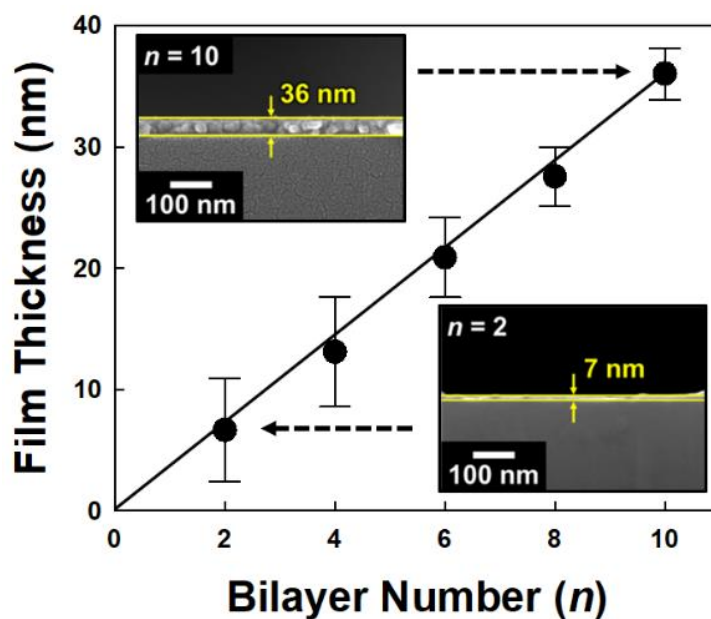
Figure S3. Thicknesses of the (TOA-Au NP/TREN)$_n$ multilayer films as a function of the bilayer number (n). The inset show the FE-SEM image of TOA-Au NP/TREN)$_{n=2 \text{ and } 10}$ multilayer films. In this case, the adsorption times of TOA-Au NPs in toluene and TREN in ethanol were 30 and 10 min, respectively. In this case, the thickness per bilayer was measured to be approximately 4 nm. Although the bilayer thickness is much thinner than the diameter of the individual TOA-Au NPs, subsequent depositions filled in the areas with insufficient surface coverage originating from sub-monolayer adsorption.

a
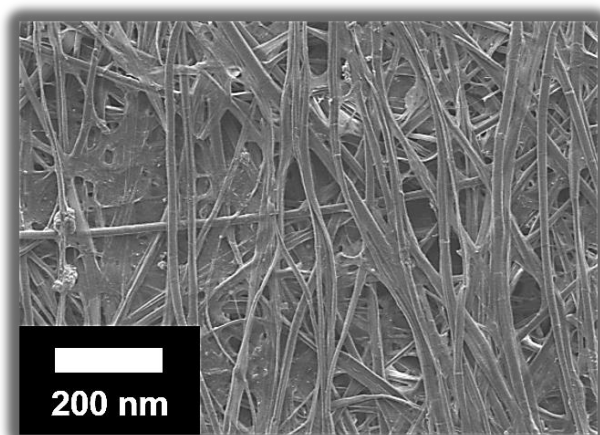
b
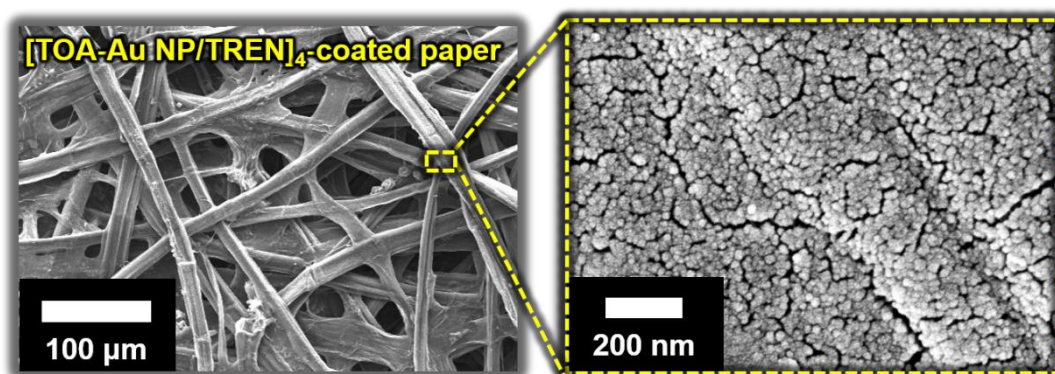
Figure S4. FE-SEM images of a) bare paper and b) (TOA-Au NP/TREN)$_4$ multilayer-coated paper.

a

b
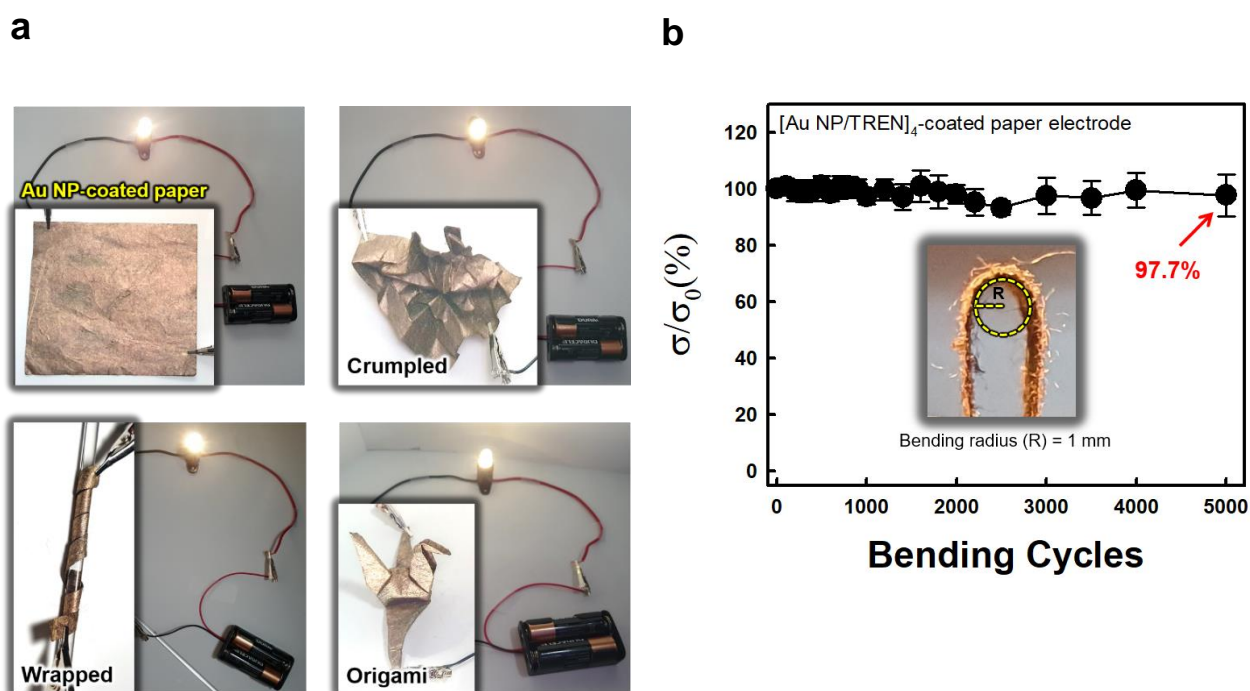
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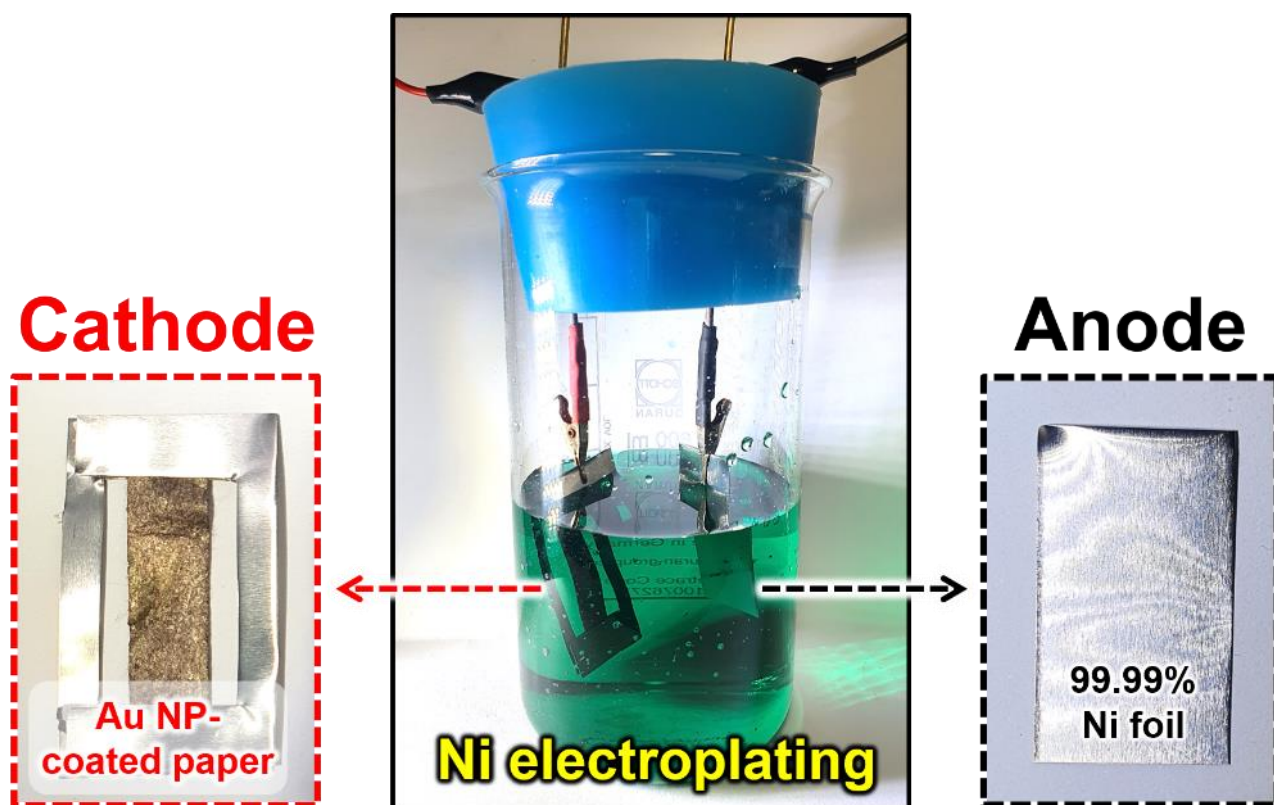
Figure S6. Photographic image of two-electrode configuration-based Ni electroplating setup. Au NP-coated paper was connected to the circuit as a cathode after being framed with Ni plate and 99.99% Ni foil was connected as an anode.
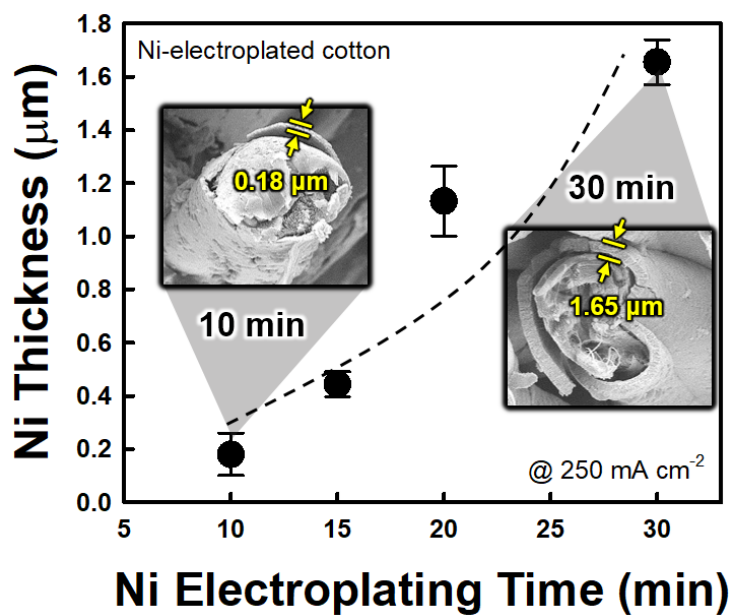
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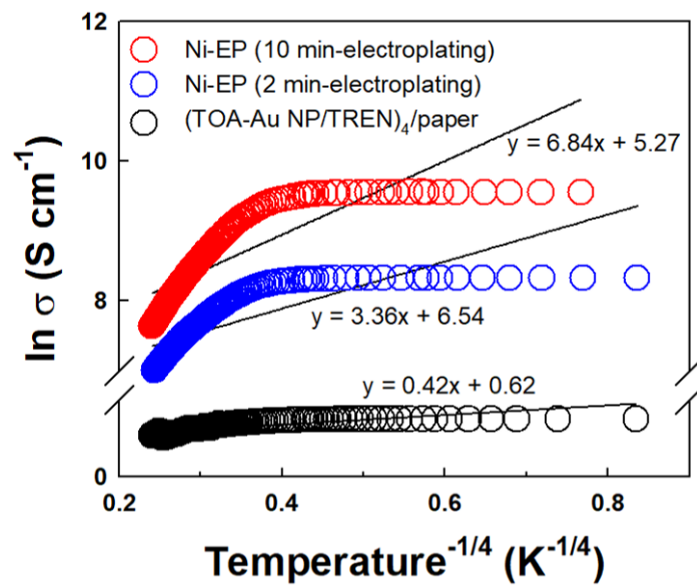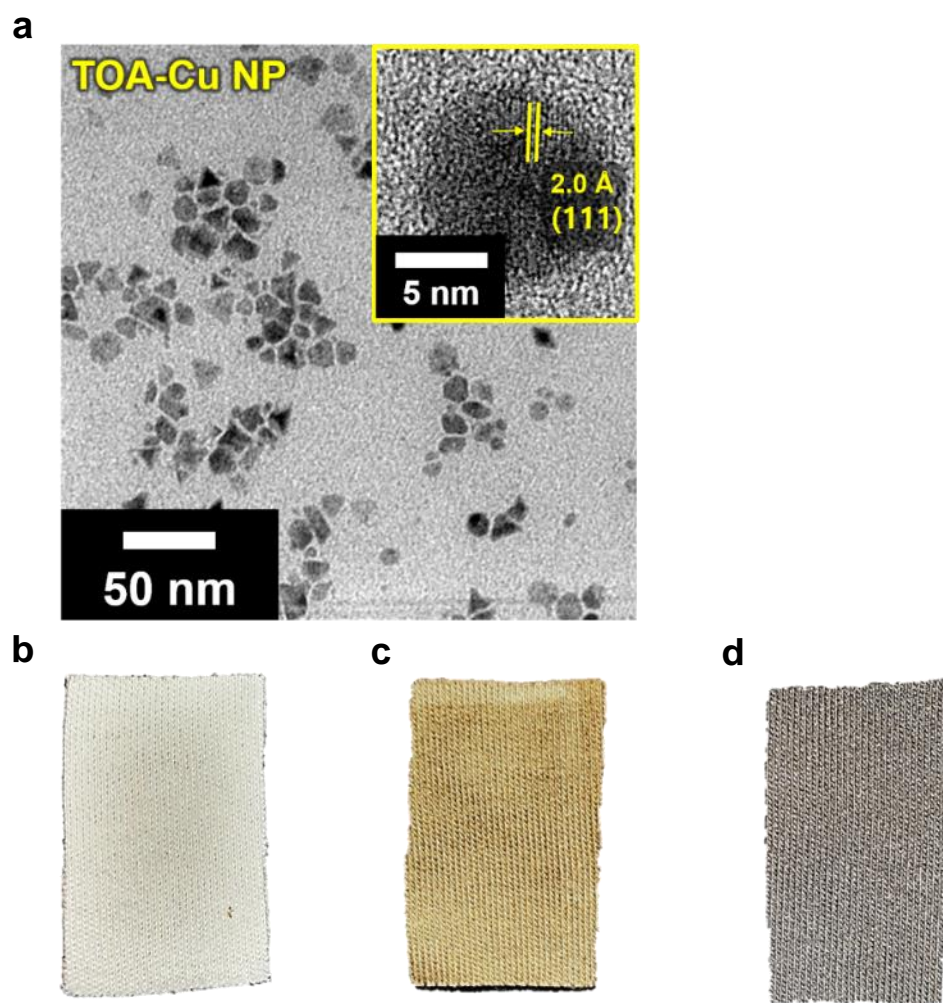
Figure S8. Plots of the conductivity (lnσ) vs. temperature ($K^{-1/4}$) for (TOA-Au NP/TREN)$_4$-paper and Ni-EPs (electroplating time = 2 and 10 min).
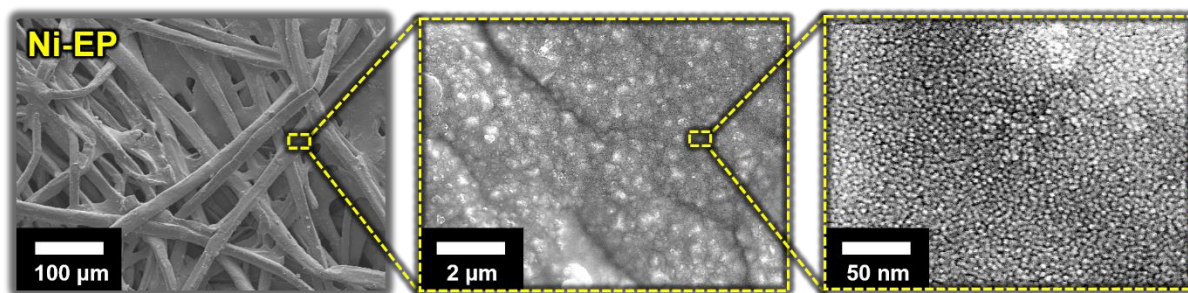
**Figure S9.** FE-SEM image of Ni-EP (i.e., electroplated Ni/(TOA-Au NP/TREN)$_4$-coated paper).

a

b
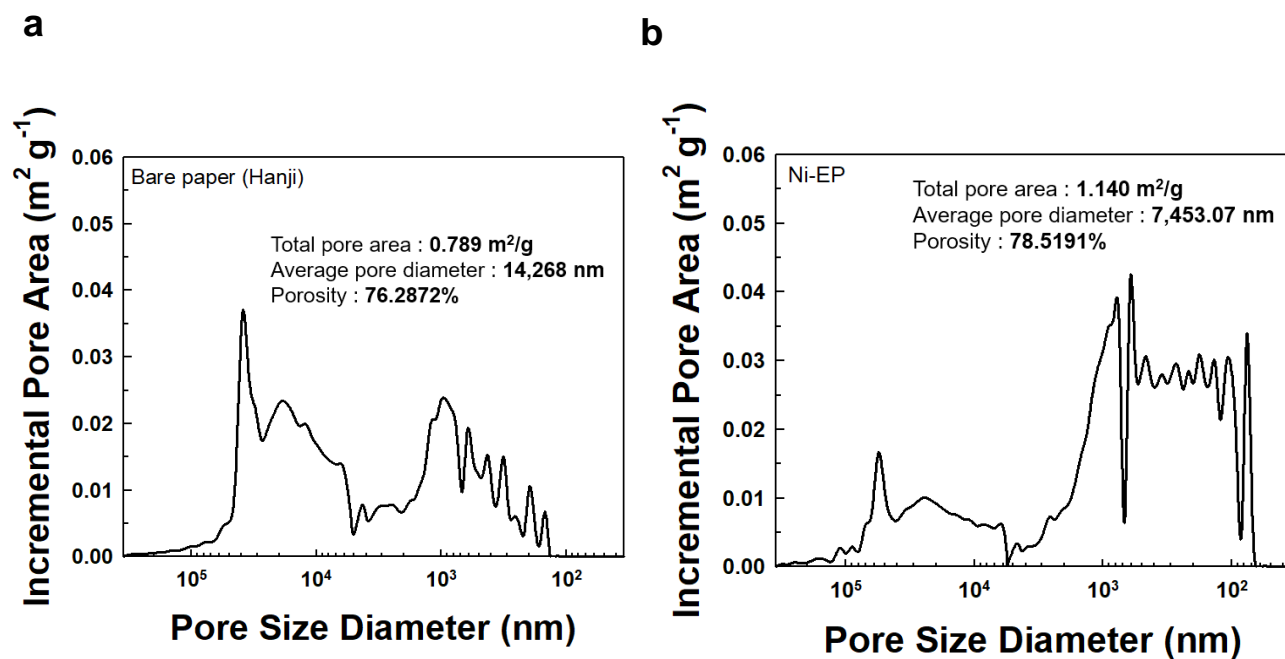
Figure S10. Incremental intrusion area of mercury versus pore diameter for a) bare paper and b) Ni–EP using mercury porosimetry technique.

Figure S11. a) HR-TEM images of TOA-Cu NP with a diameter of approximately 8.5 nm. Photographic images of b) bare, c) Cu NP-coated, and d) Ni-electroplated cotton.
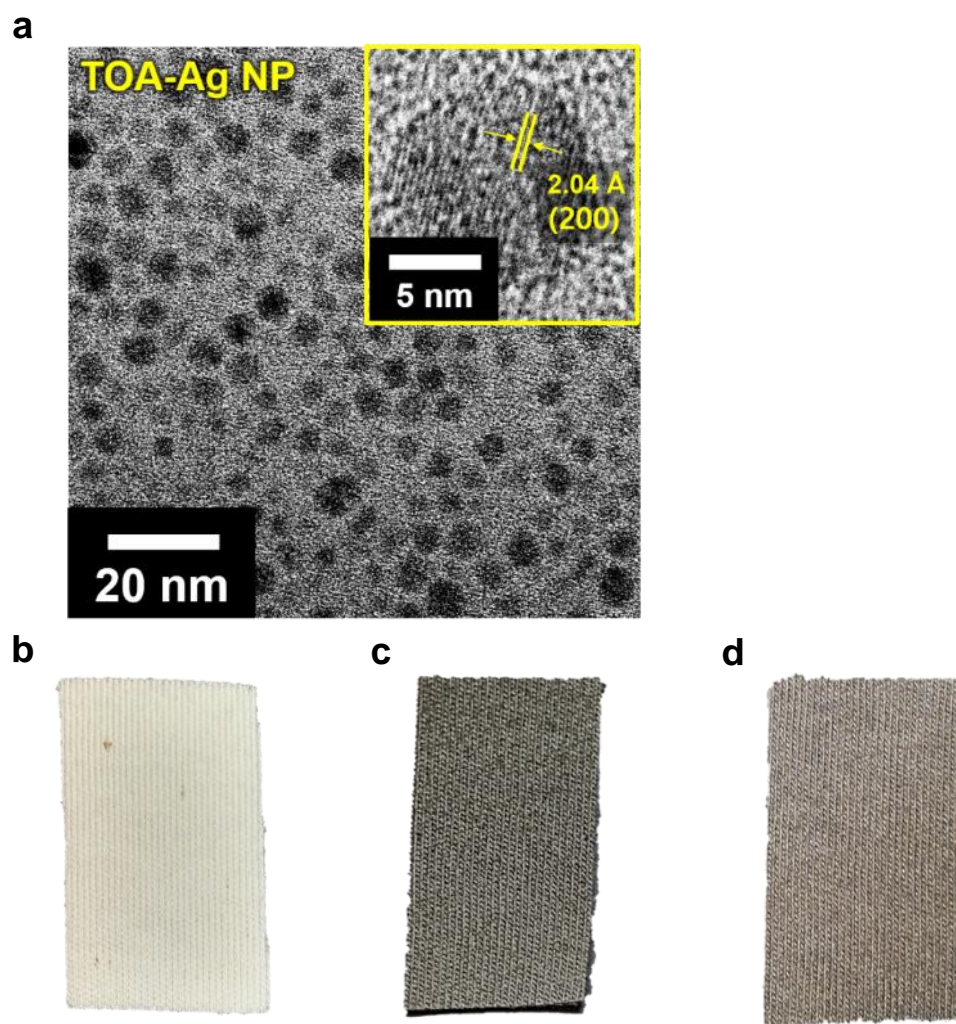
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a

b

c
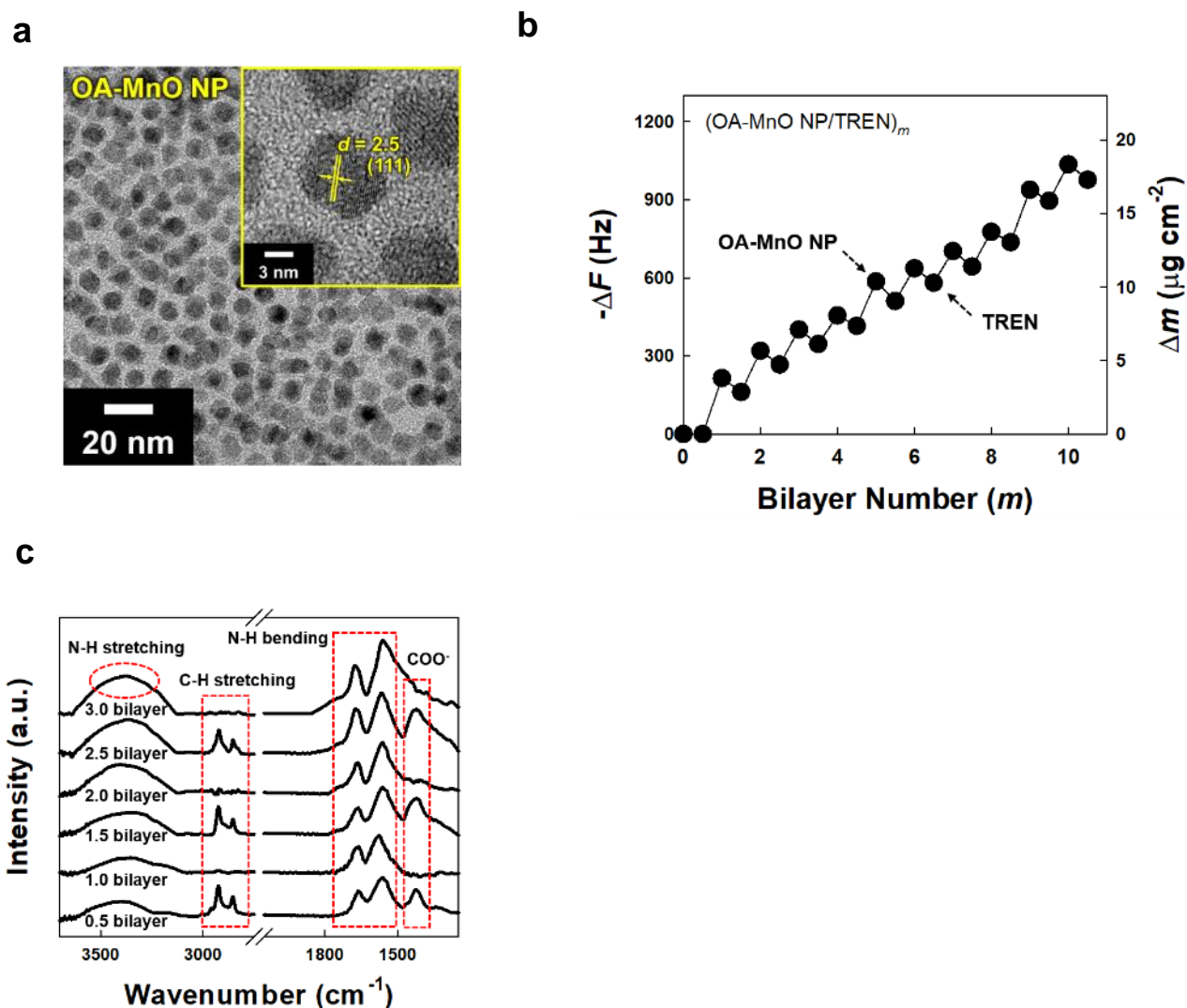
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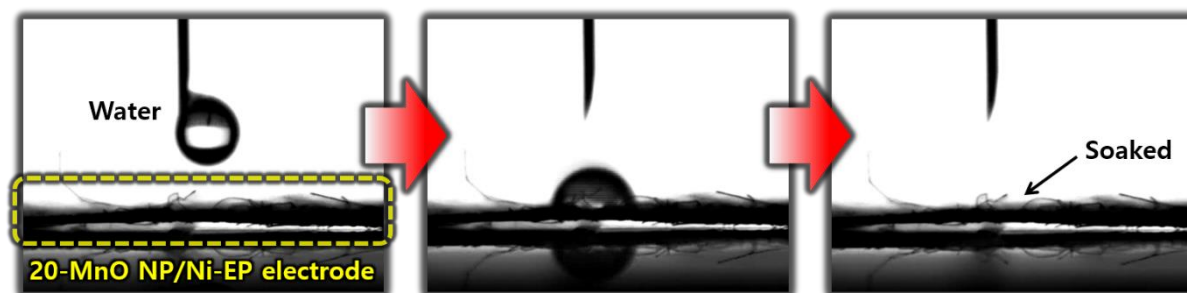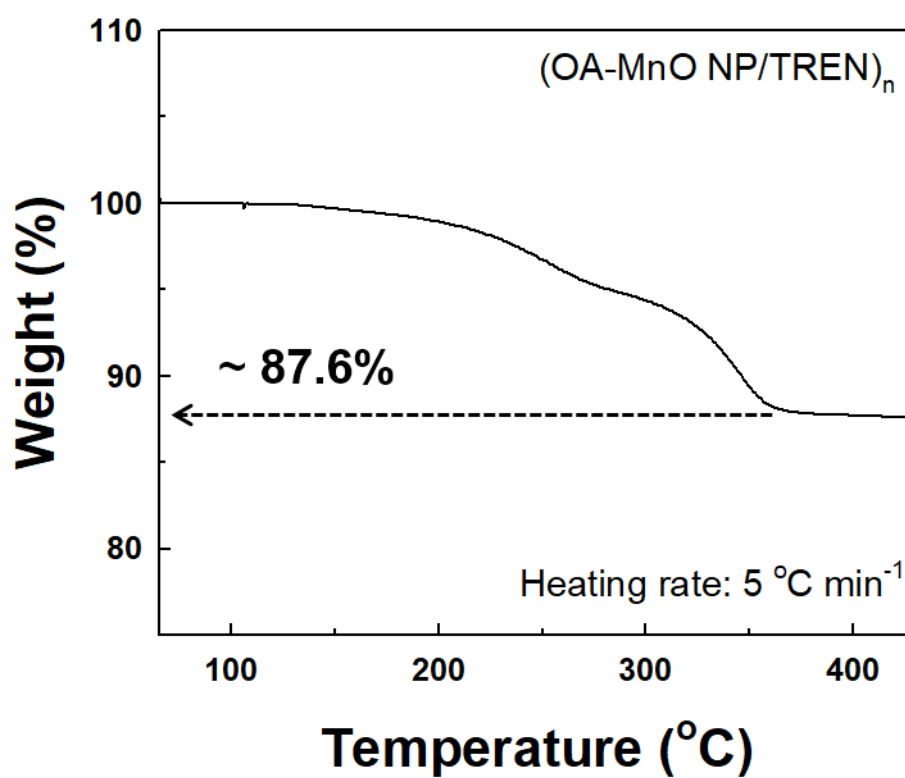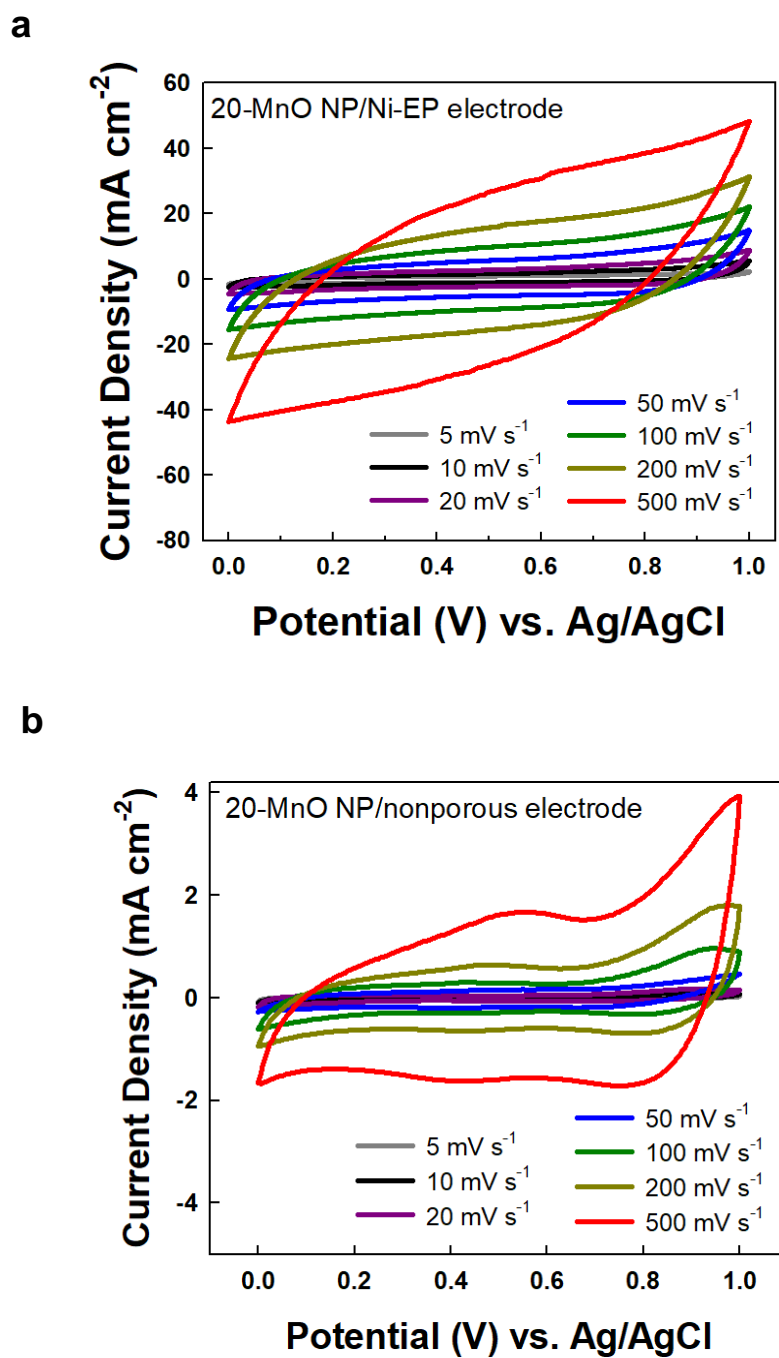
Figure S14. Photographic images of the water droplets on the 20-MnO NP/Ni-EP electrode over a short period of time.
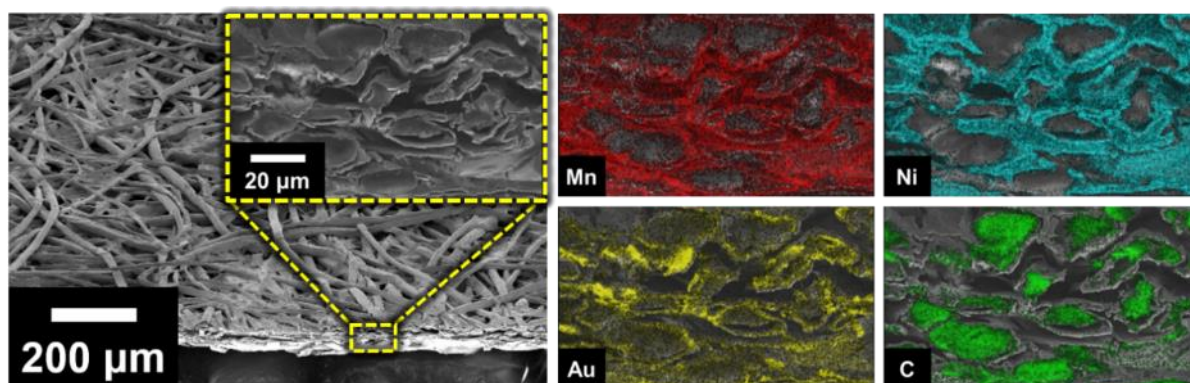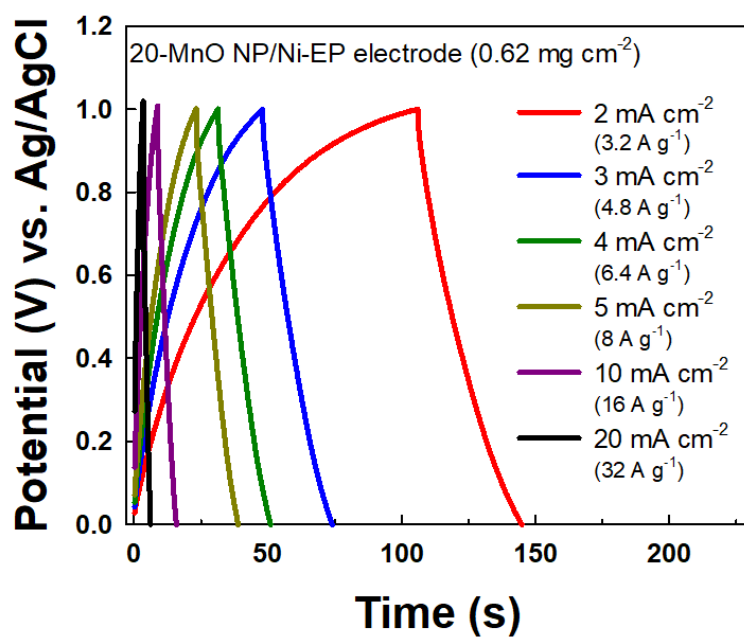
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Figure S16. TGA data of (OA-MnO NP/TREN)$_n$ nanocomposite multilayers.

a

b

Figure S17. a) CVs of the 20-MnO NP/Ni-EP electrode as a function of scan rate. b) CVs of the 20-MnO NP/nonporous electrode as a function of scan rate.

Figure S18. Galvanostatic charge/discharge (GCD) curves of the 20-MnO NP/Ni-EP electrode at various current densities in the range of 2–20 mA cm^{-2} (3.2–32 A g^{-1}).
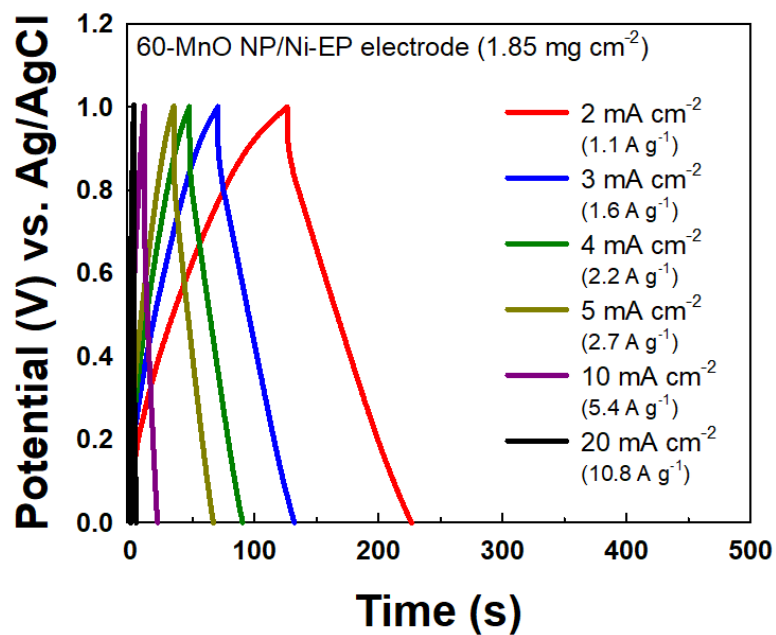
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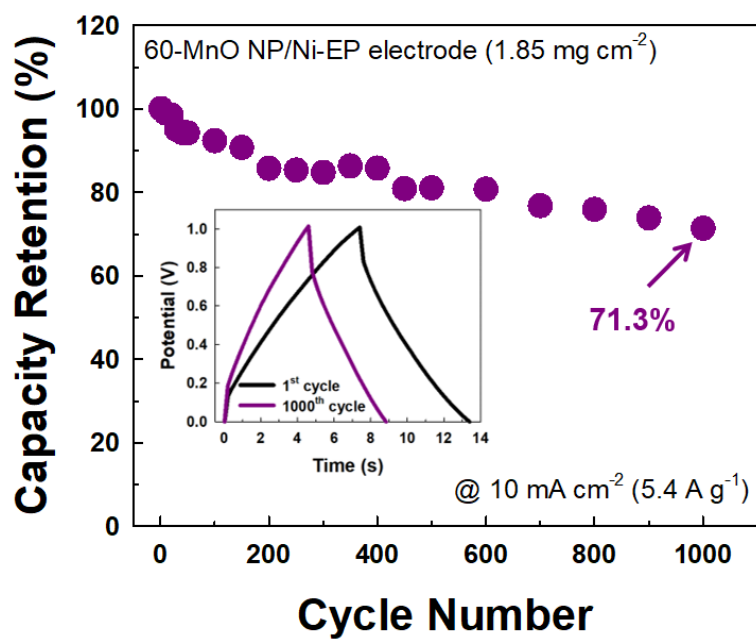
Figure S20. Cycling retention of the 60-MnO NP/Ni-EP electrode at 10 mA cm^{-2} (5.4 A g^{-1}). The inset shows the GCD curves measured after 1st and 1000th cycles.
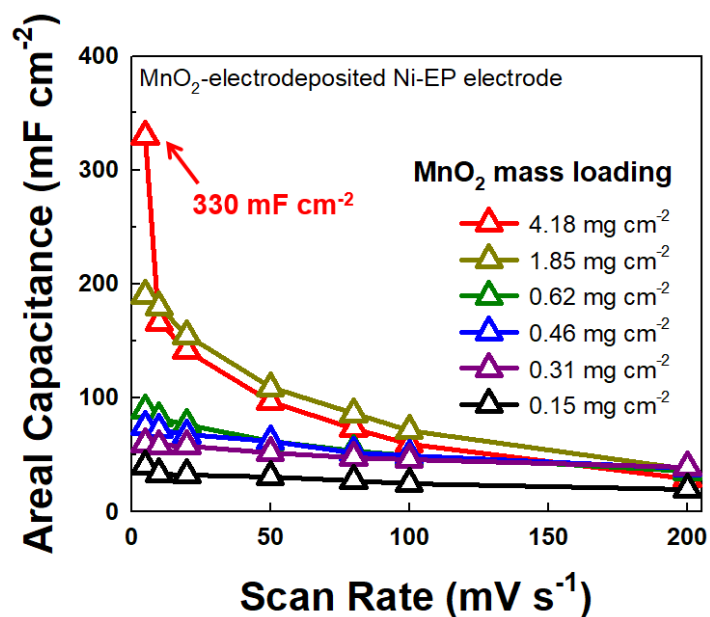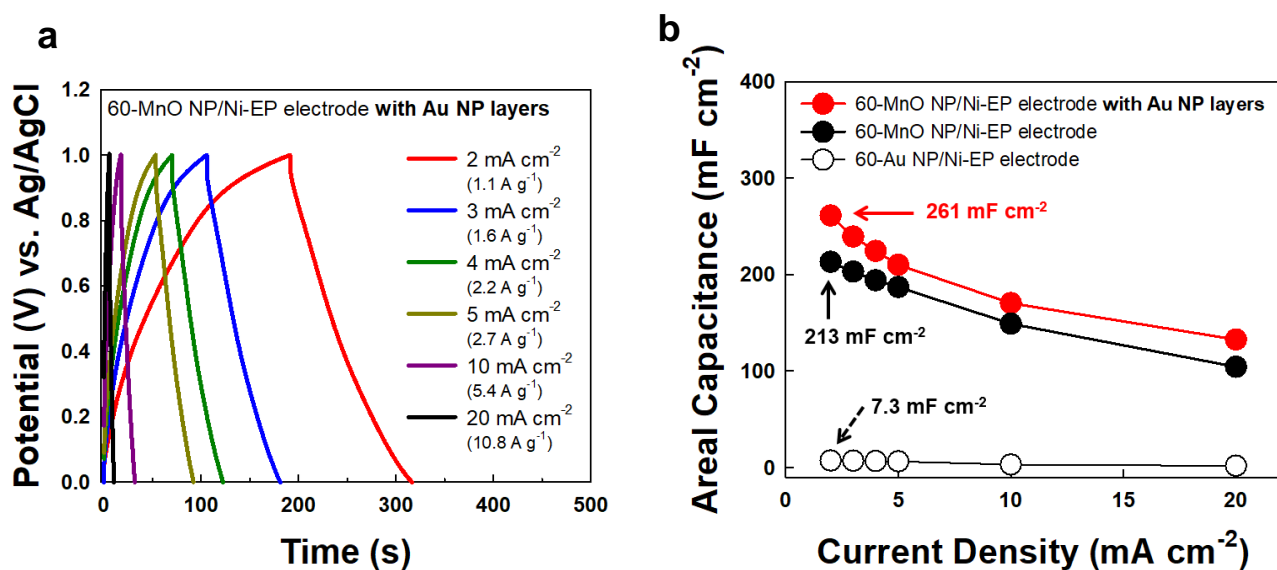
Figure S21. Areal capacitances of electrodeposited MnO₂-based Ni-EP electrodes with various mass loading densities. In the case of MnO₂-electrodeposited Ni-EP electrode with a mass loading of 4.18 mg cm⁻² (for electrodeposited MnO₂), its loading mass was similar to that of 140-MnO NP/Ni-EP electrode (mass loading of LbL-assembled MnO NPs ~ 4.18 mg cm⁻²).
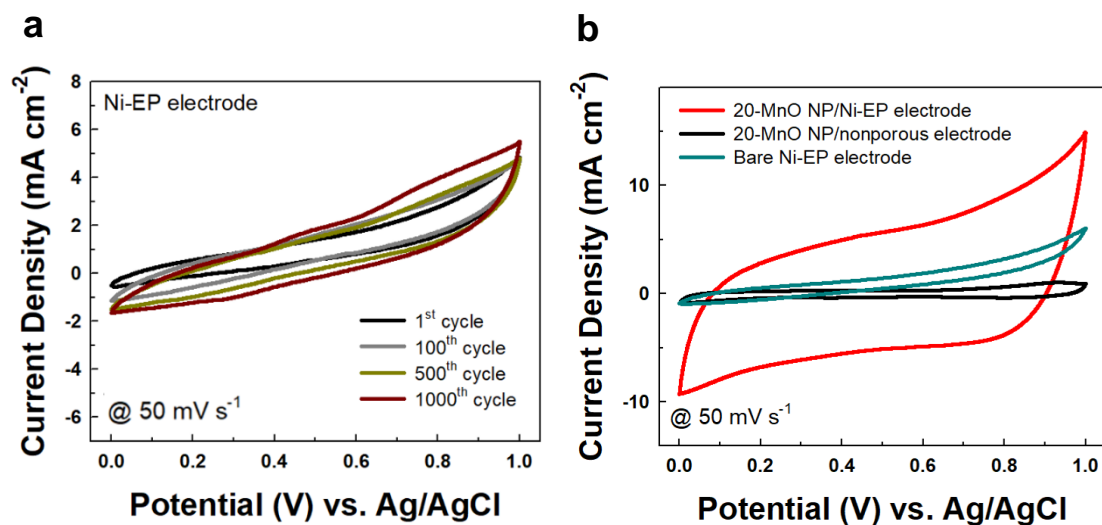
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Figure S23. a) GCD curves of the 60-MnO NP/Ni-EP electrode with Au NP layers at various current densities in the range of 2–20 mA cm^{-2} (1.1–10.8 A g^{-1}). b) Areal capacitances of 60-MnO NP/Ni-EP electrode with Au NP layers, 60-MnO NP/Ni-EP electrode, and 60-Au NP/Ni-EP electrode as a function of current densities (2-20 mA cm^{-2}).
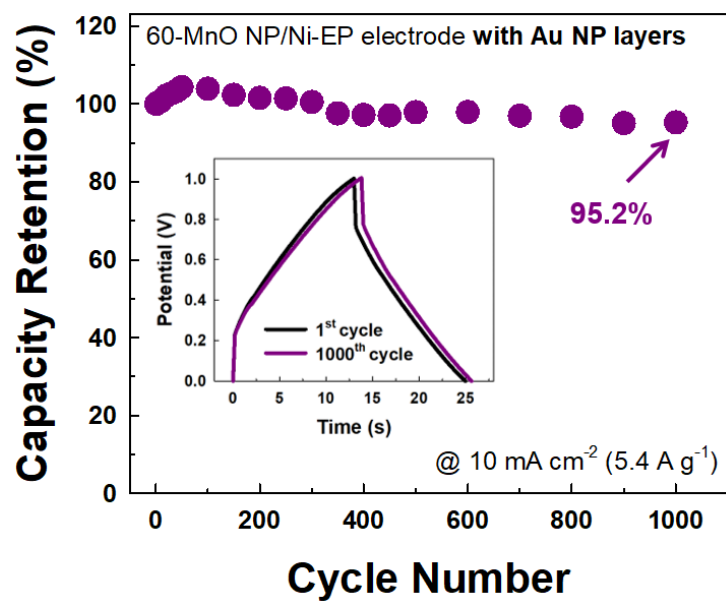
Figure S24. Cycling retention of the 60-MnO NP/Ni-EP electrode with Au NP layers at 10 mA cm^{-2} (5.4 A g^{-1}). The inset shows the GCD curves measured after 1st and 1000th cycles.
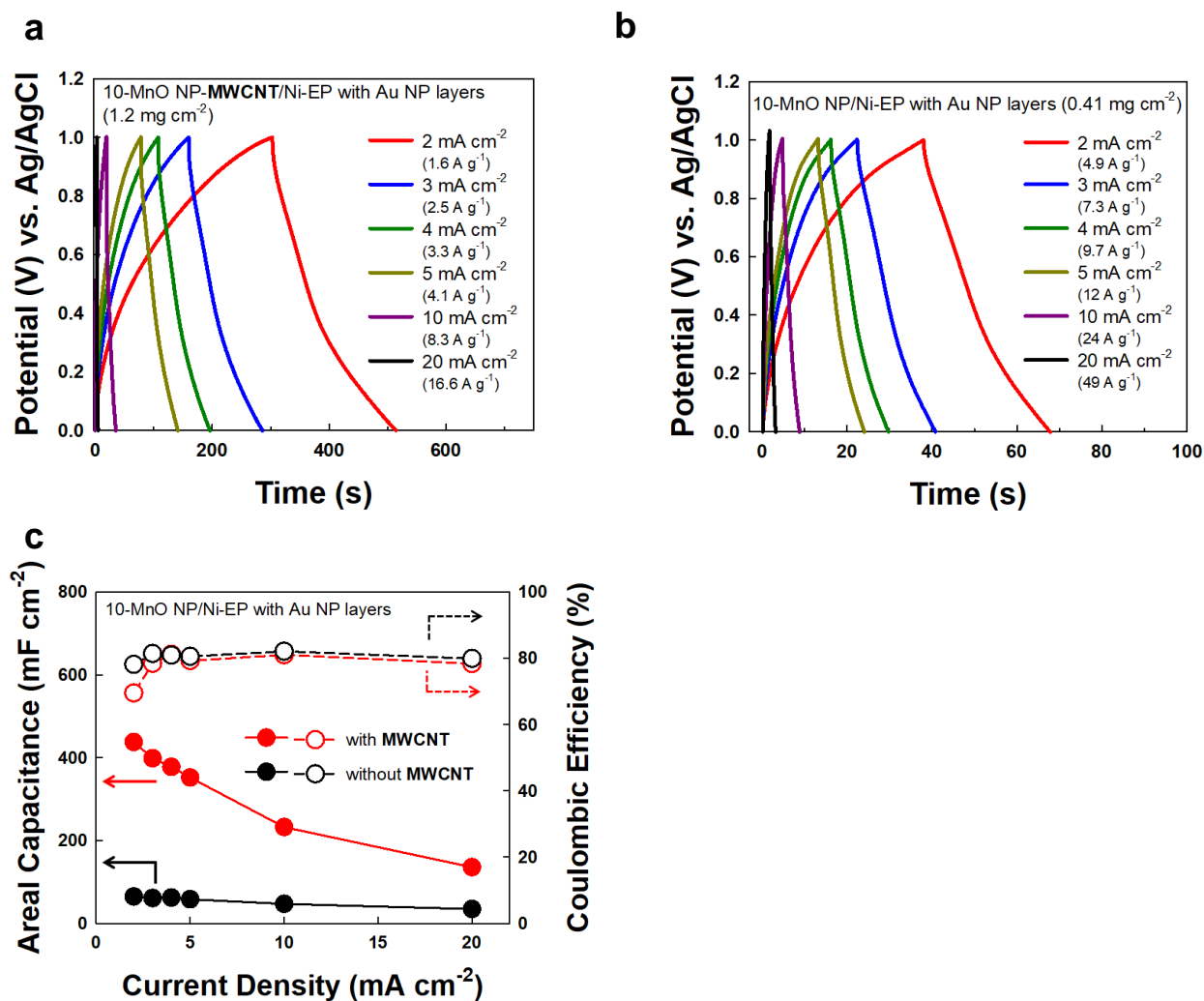
Figure S25. GCD curves of a) (MnO NP/TREN)$_{10}$/(COOH-MWCNT/TREN)$_{10}$ multilayer-coated Ni-EP electrode (i.e., 10-MnO NP-MWCNT/Ni-EP) with Au NP layers and b) 10-MnO NP/Ni-EP electrode with Au NP layers. c) Areal capacitance and Coulombic efficiencies of 10-MnO NP-MWCNT/Ni-EP with Au NP layers and 10-MnO NP/Ni-EP with Au NP layers at various current densities in the range of 2–20 mA cm^{-2}.
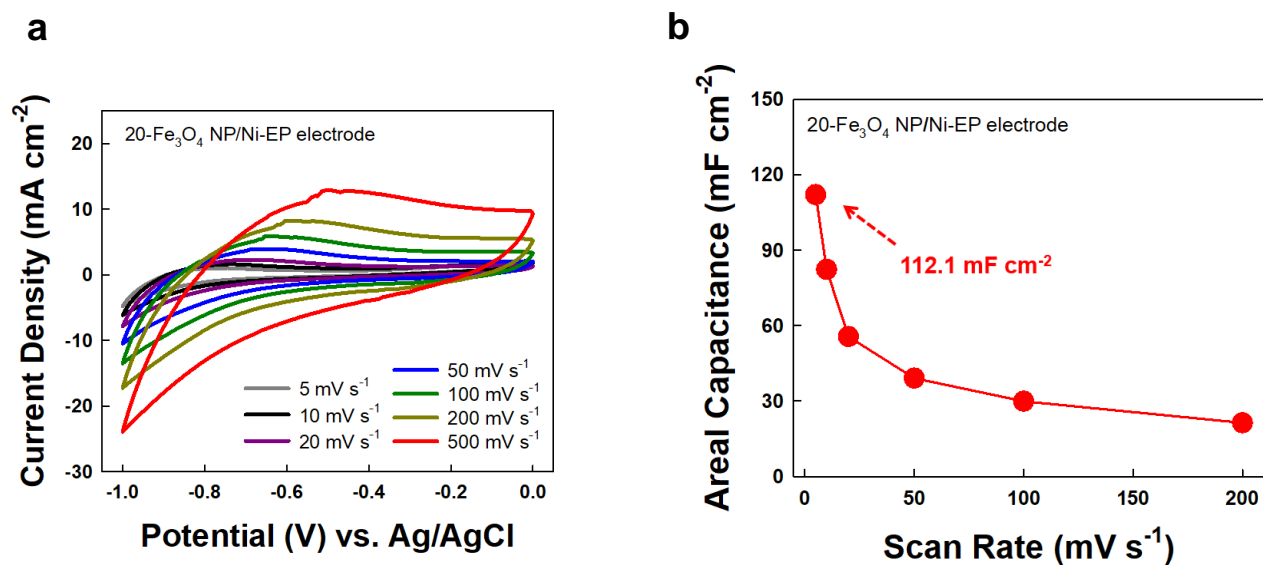
Figure S26. a) CV curves and b) areal capacitances of 20-Fe$_3$O$_4$ NP/Ni-EP electrode as a function of scan rate.
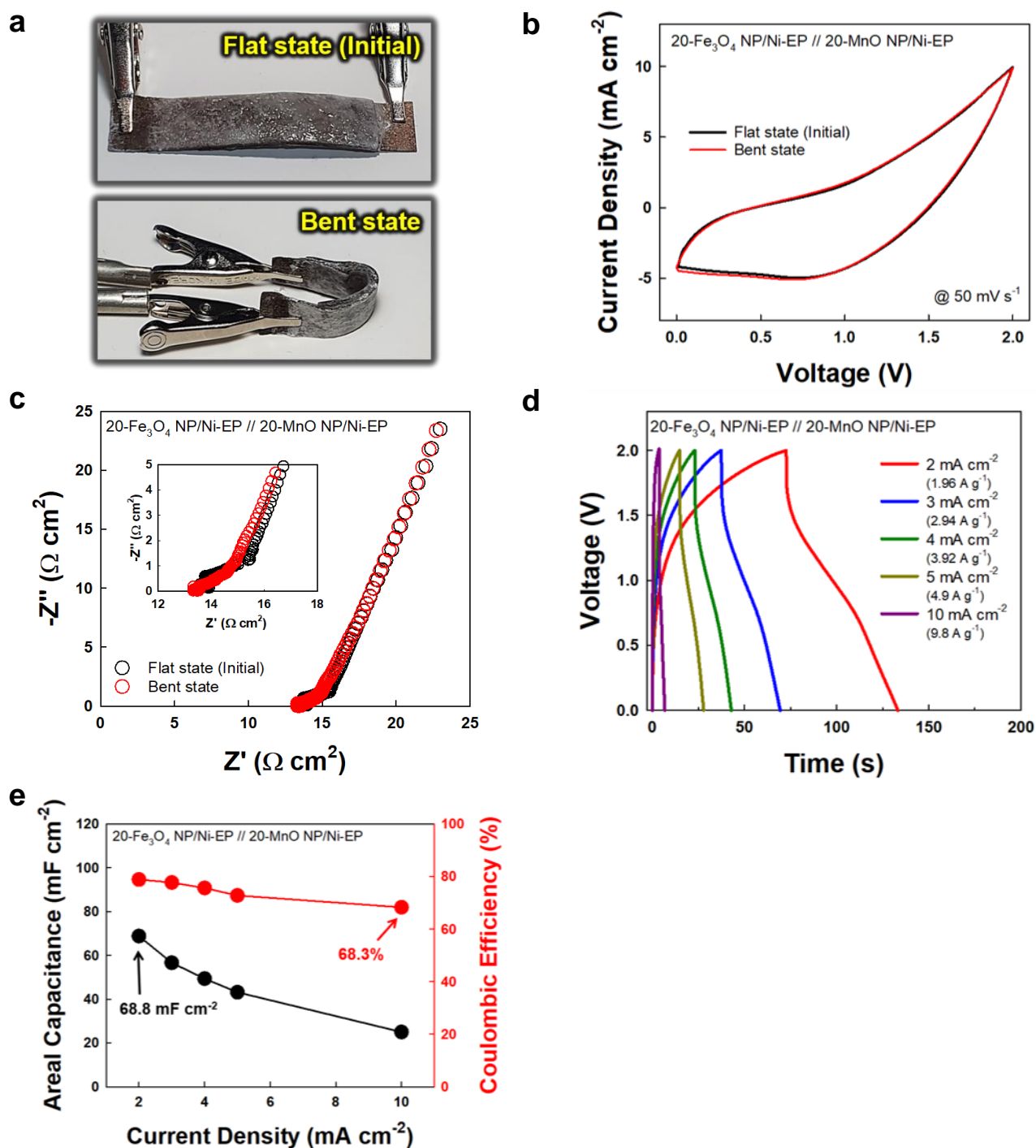
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